



# *Article* **Advancing Atomic Force Microscopy: Design of Innovative IP-Dip Polymer Cantilevers and Their Exemplary Fabrication via 3D Laser Microprinting**

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**Abstract:** This paper presents the design and fabrication of new types of polymer-based cantilevers for atomic force microscopy. The design and fabrication are aimed at the capability of 3D laser microprinting technology based on two-photon polymerization on a standard silicon substrate. IP-Dip commercial material from the Nanoscribe company was used for the fabrication of the designed cantilevers. The fabricated microprinted cantilevers facilitate precise manipulation at the nanoscopic scale, which is essential for studying nanomaterials' mechanical, electrical, and optical properties. The cantilevers' flexibility allows for the integration of functional elements such as piezoelectric layers and optical fibers, enabling combined measurements of multiple physical parameters. Various cantilever geometries, including rectangular and V-shaped, are examined, and their resonance frequencies are calculated. The experimental process involves preparing the cantilevers on a silicon substrate and coating them with aluminum for enhanced reflectivity and conductivity. Scanning electron microscope analysis documents the precise form of prepared polymer cantilevers. The functionality of the probes is validated by scanning a step-height standard grating. This study demonstrates the versatility and precision of the fabricated cantilevers, showcasing their potential for large-area scans, living cell investigation, and diverse nanotechnology applications.

**Keywords:** atomic force microscopy; cantilever; direct laser writing; polymers

### **1. Introduction**

Atomic force microscopy (AFM) enables high-resolution imaging of a sample surface based on atomic interactions between the surface and a scanning probe. This technique is crucial in many nanotechnology applications and offers different modes of scanning and material characterization on the nanoscale. The scanning probe consists of a cantilever base followed by a thin and flexible cantilever, and the most important part is the very sharp AFM tip at the end of the cantilever. Atomic interaction between the AFM tip and sample surface deflects the cantilever. Changes in the positions of the cantilever are optically detected, recorded, and evaluated.

Generally, three basic modes are used in AFM measurements: contact mode, tapping mode, and non-contact mode.

Selecting the appropriate AFM mode is crucial for achieving accurate and reliable measurements. The result is a topographic image of the sample surface with a resolution approaching the size of atoms [\[1\]](#page-7-0). Besides the standard surface mapping, modern AFM systems also allow material characterization, magnetic property mapping, and charge distribution in semiconductor materials using specially tailored probes [\[2\]](#page-7-1). The most crucial parts for the resolution and properties of AFM microscopy are the cantilever and tip. The quality of AFM cantilevers is evaluated according to several key parameters that determine their suitability for specific applications. The most important parameters of



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cantilever quality include resonance frequency, elasticity constant, quality factor, cantilever geometry, properties of the material from which the cantilever is made, tip quality (its resistance to damage), friction coefficient (tip surface), chemical resistance, production reproducibility, etc. [\[3](#page-7-2)[–6\]](#page-7-3).

The available types of commercial AFM cantilevers and tips enable researchers to select the most suitable probe for the desired application. The two most popular probe materials are monocrystalline silicon and silicon nitride [\[7\]](#page-7-4). To provide such a range of tips featuring different functionalities, numerous micro- and nano-fabrication methods and many various materials have been employed for AFM cantilever fabrication, e.g., diamonds [\[8](#page-7-5)[–11\]](#page-7-6), metals [\[12\]](#page-7-7), and various types of photopolymers [\[13\]](#page-7-8).

Cantilevers made of polymers have unique properties that make them suitable for specific areas of use, primarily in biomedical applications, studying the mechanical properties of soft materials, as chemical sensors, and for high-resolution imaging. It has been shown that the material properties of polymers permit larger frequency bandwidths [\[14\]](#page-7-9), which are suitable for high-speed imaging [\[15\]](#page-8-0). Polymer probes, thanks to their biocompatibility, can be suitable for the investigation of living cells and biological samples. Due to their flexibility, they can be used for measurements of soft and delicate samples, such as polymer gels and biomaterials. It has been shown that the hydrophobic polymeric AFM tips produced by 2PP minimize adhesion forces between the tip and sample during measurements [\[16,](#page-8-1)[17\]](#page-8-2). The light weight of polymer cantilevers, compared to silicon ones, can lead to higher sensitivity and, therefore, better resolution. The polymer material, through its mechanical properties and density, determines the stiffness, resonance frequency, and Q-factor of the AFM cantilever [\[18\]](#page-8-3). Several different approaches were considered in recent years to prepare AFM cantilevers based on polymers [\[14](#page-7-9)[–17\]](#page-8-2).

In this paper, we focus on the novel cantilever and tips prepared from polymer materials typical for 3D laser microprinting (IP-Dip). Fabrication of AFM cantilevers by 3D microprinting allows true 3D control over the resulting cantilever's shape, tip's geometry, and aspect ratio [\[15,](#page-8-0)[17\]](#page-8-2). This 3D laser microprinting opens a new platform of 3D polymerbased tips tailored to desired applications, as the geometry of the cantilever, shape, and internal structure of the tip can be customized. We offer some basic concepts of cantilevers and tips, as well as their design and fabrication on a standard silicon platform. Prepared AFM probes are finally used for scanning the calibrating grating.

### **2. Geometry of Cantilevers**

The properties of the cantilevers can then be influenced by their geometry. There are two typical geometries used for AFM cantilevers: simple rectangular geometry and V-shaped geometry (Figure [1\)](#page-2-0) [\[19\]](#page-8-4).

The stiffness of the cantilever is defined by the force constant *k* [\[20,](#page-8-5)[21\]](#page-8-6). The theoretical expression for the estimation of the force constant in the case of a simple rectangular AFM cantilever is given by the following formula:

$$
k = \frac{EWT^3}{4L^3},\tag{1}
$$

where *E* is Young's modulus, *W* is the width of the cantilever, *T* is the thickness, and *L* is the length of the cantilever [\[4\]](#page-7-10). The commonly used AFM cantilevers have force constants in a broad range of 0.01–100 N/m. The "soft" AFM cantilevers, with a *k*-parameter lower than 0.1  $N/m$ , are primarily used in the contact mode to minimize surface deformation [\[4\]](#page-7-10). Another equally important parameter is the resonance frequency. In the simplest case of a rectangular AFM cantilever, neglecting the mass of the AFM tip, the resonance frequency can be calculated using the formula:

$$
f_R = \frac{T}{4\pi L^2} \sqrt{\frac{E}{\rho}},\tag{2}
$$

<span id="page-2-0"></span>where  $\rho$  is the density of the cantilever material. It is evident that the length of the AFM cantilever is the decisive factor for the cantilever's resonance frequency. A decrease in the length L considerably increases the resonance frequency; however, it also increases the cantilever's force constant.

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**Figure 1.** Cantilever types according to geometry: (a) simple rectangular; (b) V-shaped geometry; and (c) half of a V-shaped cantilever for analysis. and (**c**) half of a V-shaped cantilever for analysis.

AFM probes with a low force constant *k* and high resonance frequencies are ideal for tap-AFM probes with a low force constant *k* and high resonance frequencies are ideal for tapping mode measurements since the AFM probe taps the specimen surface while vibrating at several hundred kHz [\[9\]](#page-7-11). We calculated the resonance frequencies for cantilever thicknesses ranging from 6 to 20  $\mu$ m with a step of 2  $\mu$ m and cantilever lengths L from 150 to 220  $\mu$ m with a step of 10  $\mu$ m. Here, we considered  $E = 2$  GPa (Young's modulus for IP-Dip ranges from 0.75 GPa to 2.5 GPa depending on the applied laser power during the polymerization process)  $[22]$ . As shown in Figure [2,](#page-2-1) the resonance frequencies of the rectangular cantilever are in the range of several tens of kHz. To achieve resonance frequencies of around 100 kHz, we would have to significantly increase the cantilever thickness or consider the second V-shaped cantilever geometry. ron in -Dip ranges from 0.75 GPa to 2.5 GPa depending on the applied laser power during the material

<span id="page-2-1"></span>

Figure 2. Resonant frequencies of rectangular cantilevers as a function of length at variable thickness.

To calculate the resonance frequency of the V-shaped cantilever for AFM microscopy, we employed an analytical solution based on the Rayleigh–Ritz method, as detailed and compared with simulations in the article [\[23\]](#page-8-8). The geometry of a V-shaped cantilever can be conceptualized as the difference between two triangular cantilevers (refer to Figure [1b](#page-2-0)), each with lengths *L*<sup>0</sup> and *L*<sup>1</sup> and widths *W*<sup>o</sup> and *W*1, respectively. It can be easily concluded that, due to the mirror symmetry of the V-shaped cantilever, it is sufficient to analyze only

half of the cantilever, represented by a quadrilateral shape as depicted in Figure [1c](#page-2-0). For calculation convenience, it is reasonable to define the width ratio *m* and the length ratio *n*<br>
for the calculation of the V-shaped cantilever as follows: that, or the cantilever, represented by a quadriancial shape as depicted in Figure 1

$$
m = \frac{W_0}{W_1}, \ \ n = \frac{L_0}{L_1}.
$$
\n(3)

The resonant frequency of a V-shaped cantilever is then: The resonant frequency of a V-shaped cantilever is then:

$$
f_V = \frac{T}{2\pi L_1^2} \sqrt{\frac{70E}{\rho}} \sqrt{\frac{3 - 6mn + 4mn^2 - mn^3}{49 - 84pm + 40mn^6 - 5mn^7}}.
$$
 (4)

From the given equation, the thickness  $T$  and the length  $L_1$  exert the greatest influence on the resonance frequency. Considering the technological constraints of direct laser writing (DLW) lithography and the mechanical properties of the IP-Dip polymer, we calculated the resonance frequencies for cantilever thicknesses ranging from  $5$  to  $9 \mu m$  with a step of  $0.5 \mu$ m and cantilever lengths *L*<sub>1</sub> from 150 to 220  $\mu$ m with a step of 10  $\mu$ m. We adjusted the parameters *m* and *n* to a value of 0.5 ( $W_1$  = 100  $\mu$ m and  $W_0$  = 50  $\mu$ m, where  $L_0$  is calculated according to *L*<sub>1</sub>). Figure 3 shows the graph of the calculated frequencies. Each line represents the frequencies of the cantilever of a certain thickness, *T*, dependent on *L*<sub>1</sub>. V-shaped cantilevers can reach a higher resonant frequency (compared to rectangular cantilevers with similar dimensions) and exhibit their sensitivity. According to preliminary calculations, selecting an appropriate cantilever geometry allows us to achieve a theoretical resonance frequency ranging from one kilohertz for a rectangular cantilever to approximately 150 kHz for a V-shaped cantilever.

<span id="page-3-0"></span>

**Figure 3.** Resonant frequencies of a V-shaped cantilever as a function of length and thickness. **Figure 3.** Resonant frequencies of a V-shaped cantilever as a function of length and thickness.

## **3. Experimental 3. Experimental**

For the fabrication of the nanoprobes, a commercial 3D laser lithography system,  $\overline{G}$ Photonic Professional GT from Nanoscribe GmbH, operating on the principle of twophoton absorption within a polymer matrix, was used. The dielectric polymer material  $\overline{P}$ IP-Dip, known for its suitable mechanical and optical properties, was employed in this process [\[24–](#page-8-9)[27\]](#page-8-10). The microprinted cantilevers produced through this method facilitate highly precise manipulation at the nanoscopic scale, including the manipulation of molecules and nanoparticles. These cantilevers can be used to study nanomaterials in detail, including their mechanical, electrical, and optical properties. Additionally, the flexibility in the design makes it possible to create cantilevers with integrated functional elements, such as piezoelectric layers or optical fibers, which enable combined measurements of multiple physical parameters.

A silicon wafer in the shape of a rectangle with dimensions of 3  $\times$  5 mm was used as the base or chip of the AFM probe. A cantilever with a tip was prepared at its edge, as the base or chip of the AFM probe. A cantilever with a tip was prepared at its edge, as depicted in Figure 4. To ensure a firm connection of the cantilever to the chip, one end of the depicted in Figure [4.](#page-4-0) To ensure a firm connection of the cantilever to the chip, one end of cantilever is widened, as shown in the IP-Dip base in Figure  $4$ . Prior to the microprinting process, the silicon wafer was treated with isopropyl alcohol (IPA) to remove impurities from its surface. Subsequently, the liquid polymer IP-Dip was applied to the edge of the silicon wafer.

piezoelectric layers or optical fibers, which enable combined measurements of multiple

<span id="page-4-0"></span>

**Figure 4.** Illustration of designed deployment of parts of IP-Dip cantilever. **Figure 4.** Illustration of designed deployment of parts of IP-Dip cantilever.

The lithography process was divided into three steps. In the first step, we printed the IP-Dip base on the silicon substrate (Figure 4). The femtosecond laser beam reflection from IP-Dip base on the silicon substrate (Figure [4\)](#page-4-0). The femtosecond laser beam reflection from the silicon substrate caused the standing wave phenomenon with variable laser power in the silicon substrate caused the standing wave phenomenon with variable laser power in the vertical direction. This was reflected in the nitrogen being released from the polymer the vertical direction. This was reflected in the nitrogen being released from the polymer in the form of bubbles in the last with higher last with higher power. Therefore, we had to adjust the form of in the form of bubbles in the layers with higher laser power. Therefore, we had to adjust<br>the form of bubbles in the layers with higher laser power. Therefore, we had to adjust the printing on this substrate by reducing the laser power to  $P = 24$  mW. Subsequently, we focused on the preparation of the cantilever-protruding part. Since the cantilever was printed without supports, we maximized the scanning speed up to 40,000  $\mu$ m/s and the laser power to *P* = 36 mW, setting the slicing structure to 200 nm. In the third step, the tip was prepared at the end of the cantilever. To prepare the tip with the smallest possible tip was prepared at the end of the cantilever. To prepare the tip with the smallest possible the  $\alpha$ diameter, we used laser power *P* = 18 mW and a slicing distance of 100 nm.

Following the lithography process, the structure was developed in Propylene Glycol Mono Methyl Ether Acetate (PGMAE) and then rinsed in IPA. To enhance the reflectivity of the cantilever surface for AFM analysis, the backside of the cantilever was coated with aluminum using the K975X Turbo-Pumped Thermal Evaporator. Another advantage of this cantilever metallization is the improved conductivity, as the cantilevers prepared from polymers are prone to electrostatic charge accumulation, and a charged AFM tip results in distortion of the images.

### Using 3D microprinting, we achieved high-quality polymer rectangular cantilevers **4. Results and Discussion**

Using 3D microprinting, we achieved high-quality polymer rectangular cantilevers prepared on a silicon substrate. The prepared cantilevers were investigated using a scanning electron microscope (SEM) (Tescan Lyra3). The top view of the entire cantilever can be seen in Figure [5a](#page-5-0). On the detailed view of the tip in Figure [5b](#page-5-0), the 100 nm slicing effect on the tip height can be observed. The radius of the prepared tip was 200 nm. The repeatability of the process is documented in Figure [5c](#page-5-0), which shows a series of prepared cantilevers on a silicon substrate. The prepared cantilevers reflect the designed geometry very well, featuring a very sharp tip reaching hundreds of nanometers.

In addition, to demonstrate the capabilities of the microprinting system, we prepared other models of AFM cantilevers (see Figure [6a](#page-6-0)). To ensure better attachment of the cantilever to the silicon wafer, we enlarged the IP-Dip base. As a very promising area of



(**c**)

AFM probe printing, we also demonstrate controlled microstructure architecture (CMA) design [\[28\]](#page-8-11). We prepared an exemplary tetrahedron skeleton as the CMA tip (Figure [6b](#page-6-0)).<br>
AFM probe printing, we also demonstrate controlled microstructure architecture (CMA design [28]. We prepared an exemplary tetrahedron design  $[28]$ . We prepared an exemplary tetrahedron skeleton as the CMA tip (Figure 6b).

<span id="page-5-0"></span>be seen in Figure 5a. On the detailed view of the tip in  $\mathcal{L}_{\mathcal{S}}$  in  $\mathcal{S}$ 

**Figure 5.** SEM images of all-polymer cantilevers with the nanoconical shape of a tip prepared from **Figure 5.** SEM images of all-polymer cantilevers with the nanoconical shape of a tip prepared from IP-Dip material: (**a**) overall top view of a cantilever with a tip; (**b**) detailed view of a nanoconical tip of a cantilever; and (**c**) side view of three cantilevers with a nanoconical shape of the tip prepared on the edge of Si substrate.

100 µm

The functionality of the probe was examined by scanning the Step Height Standard calibrating grating from Applied NanoStructures, Inc., Mountain View, CA, USA, with a height of 100 nm and a pitch of 10 µm. The AFMWorkshop HR-2D atomic force microscope in contact mode was used for the experimental characterization of prepared cantilevers. After aligning the necessary AFM components, we detected the reflection of light from the surface of the cantilever using a four-quadrant photodetector, which is divided into four sections. The control software measures two channels: The top–bottom channel (T-B) and the Z-Drive channel. Channels were measured in parallel, which gives us two different data sets for the same investigated area. The T-B signal was obtained from the difference in light

intensity detected by the upper and lower parts of the detector (as illustrated in Figure [7a](#page-6-1)). The T-B signal provides a more plastic interpretation of the measured sample surface. The z-drive channel obtained data from piezo-scanner positions (Figure [7b](#page-6-1)). It allows us to measure and evaluate the vertical profile of the sample. Figure [7c](#page-6-1) shows the height profile along line 1 (from Figure [7b](#page-6-1)). The obtained data were processed in Gwyddion software, version 2.61 and the measured profile shows promising agreement with the parameters of the calibration sample with a 15 nm deviation in the vertical direction.

<span id="page-6-0"></span>



<span id="page-6-1"></span>

Figure 7. (a) AFM amplitude image of calibrating grating obtained using a prepared IP-Dip cantilever with a nanoconical shape of the tip; (**b**) AFM image obtained from Z-drive scanning; and corresponding height profile along line 1. (**c**) corresponding height profile along line 1.

### **5. Conclusions**

This study demonstrates new types of AFM probes prepared by 3D laser microprinting. The advantage of this type of preparation of cantilevers and tips is the great variability of their shapes, which leads to different stiffness and resonance frequencies focused on a broad spectrum of applications. We designed the full polymer cantilevers with nanoconical tips, and we exemplary fabricated them using 3D microprinting single-process technology. In this paper, we have also outlined other possible cantilever and tip designs, such as those with controlled microstructure architecture (CMA). The quality of the prepared probes was examined using SEM, and their functionality was validated by scanning a Step Height Standard grating by AFM. The results demonstrated promising agreement with the expected parameters with a 15 nm deviation in the vertical direction, showcasing the excellent potential of these cantilevers for high-resolution imaging and precise surface characterization on large areas.

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